

**Erratum: “Sodium Silicate Based Thermal Interface Material for High Thermal Contact Conductances”**  
[ASME J. Electron. Packag., 122, No. 2, pp. 128–131]

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In the above paper, p. 130, in the title of Table 1, cm should be changed to m in the denominator of the unit for thermal contact conductance.

**Erratum: “Development of Glass-Free Metal Electrically Conductive Thick Films”**  
[ASME J. Electron. Packag., 123, No. 1, pp. 64–69]

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In the above paper, p. 65, subsection “Sample Preparation and Air Firing Process,” the last line of the subsection, 850 C should be changed to 850 F.